

L. Nelson
2/Pre Amended
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Andreas Norbert Wiswesser, et al. Art Unit : Unknown
 Serial No. : Unknown Examiner : Unknown
 Filed : May 8, 2001
 Title : METHOD AND APPARATUS FOR DETERMINING POLISHING ENDPOINT
 WITH MULTIPLE LIGHT SOURCES

Commissioner for Patents
 Washington, D.C. 20231

PRELIMINARY AMENDMENT

Prior to examination, please amend the application as follows:

In the Title:

Please delete the current Title and insert the following:

--METHOD AND APPARATUS FOR DETERMINING POLISHING ENDPOINT
 WITH MULTIPLE LIGHT SOURCES--

In the specification:

At page 1, line 6, insert the following paragraph:

--The present application is a continuation of U.S. Patent Application Serial No.

09/237,472, filed January 25, 1999.

now US.. Patent No. 6,247,998

In the claims:

Cancel claims 24-33, 35 and 46-54.

Amend claims 1, 36, 43, 45 and 58 as follows:

1. (Amended) An apparatus for use in chemical mechanical polishing a substrate,
 comprising:

a first optical system including a first light source to generate a first light beam to
 impinge on the substrate, the first light beam having a first effective wavelength, and a first

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